WEST Search History

DATE: Thursday, June 19, 2003

Set Name Query side by side		Hit Count	Set Name result set	
DB=JB	PAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ			
L39	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)) or \$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) and ((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) and (decomposit\$7)))	1	L39	
$DB=USPT,PGPB;\ PLUR=YES;\ OP=ADJ$		• .		
L38	L37 not (L33 or L34)	5	L38	
L37	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)) or \$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) same ((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	13	L37	
DB=JB	PAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ			
L36	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	0	L36	
DB = U	SPT,PGPB; PLUR=YES; OP=ADJ			
L35	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	· 1	L35	
L34	L33 not L32	3	L34	
L33	(\$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	8	L33	
L32	L7 and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	. 5	L32	
DB=JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ				
L31	(substrate near2 temperature) and (wall near2 temperature) and (ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)))	. 1	L31	
L30	((substrate near2 temperature) same (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3 or independent\$4 or separat\$5 or seperat\$5 or differ\$4 or higher or lower or hot or hotter or cold or colder or cool or cooler) same (wall near2 temperature))	36	L30	
L29	L28 not L27	23	L29	
	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or			

L28	condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	27	L28	
L27	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3 or adjust\$4 or maintain\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	7	L27	
DB=USPT,PGPB; PLUR=YES; OP=ADJ				
L26	L25 and (ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)))	0	L26	
L25	L24 not (L12 or L13 or L14)	40	L25	
L24	((substrate near2 temperature) with (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3 or independent\$4 or separat\$5 or seperat\$5 or differ\$4 or higher or lower or hot or hotter or cold or colder or cool or cooler) with (wall near2 temperature))	64	L24	
L23	L22 not (L21 or L11)	31	L23	
L22	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (wall) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	55	L22	
L21	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and (((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) and (decompos\$8)) near8 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	7	L21	
L20	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	299	L20	
L19	L18 not L8	66	L19	
L18	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3 or adjust\$4 or maintain\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	88	L18	
L17	L16 not L11	15	L17	
L16	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (wall)))	48	L16	
L15	L14 not (L12 or L13)	13	L15	
L14	L7 and ((substrate near2 temperature) with (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3) with (wall near2 temperature))	16	L14	

L13	L7 and ((substrate near2 temperature) with (independent\$3 or seperat\$4 or separat\$4) with (wall near2 temperature))	3	L13
L12	L7 and ((substrate near2 temperature) with (differ\$4 or higher or lower or hot or hotter or cool or cooler or cold or colder) with (wall near2 temperature))	, 9	L12
L11	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	89	L11
L10	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell)))	. 160	L10
- L9	L8 not (L1 or L2)	18	L9
L8	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	22	L8
L7	L4 or L5 or L6	8243	L7
L6	(118/724).ccls. or ((118/725)!.CCLS.)	2341	L6
L5	(118/715).ccls. or (118/719).ccls. or ((118/728)!.CCLS.)	3889	L5
L4	(427/248.1).ccls. or (427/255.23).ccls. or (427/255.28).ccls. or (427/255.7).ccls. or (427/587).ccls. or (117/84).ccls. or (117/88).ccls. or (117/105).ccls. or ((117/85)!.CCLS.)	3533	L4
DB=JB	PAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L3	(Bondestam or Lindfors or ASM) and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	1	L3
DB = U	SPT,PGPB; PLUR=YES; OP=ADJ		
L2	(Bondestam in or Lindfors in or ASM as.) and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	4	L2
L1	6579374.pn. or 6562140.pn.	2	L1